

Title (en)

METHOD AND DEVICE FOR CLEANING HIGH-VOLTAGE CARRYING INSTALLATION COMPONENT PARTS

Title (de)

REINIGUNGSVERFAHREN UND -VORRICHTUNG FÜR HOCHSPANNUNGSFÜHRENDE ANLAGENTEILE

Title (fr)

PROCEDE ET DISPOSITIF DE NETTOYAGE POUR ELEMENTS D'INSTALLATION A HAUTE TENSION

Publication

**EP 1263549 B1 20030806 (DE)**

Application

**EP 01923519 A 20010315**

Priority

- DE 0100994 W 20010315
- DE 10012426 A 20000315

Abstract (en)

[origin: US2003104764A1] The invention relates to a cleaning method and to a corresponding cleaning device, which offer adequate protection to individuals, devices and installations, for cleaning component parts of installations that carry an electrical high-voltage and are not disconnected during cleaning. To this end, the component parts to be cleaned are subjected to the action of a two-phase particle stream (PS) consisting of a compressed gas (DGA) serving as a carrier medium and of carbon dioxide ice particles (TP) carried therein. Possible superficial accumulations of dirt are removed from the component parts by means of low-temperature brittleness and by the kinetic energy of the impacting carbon dioxide particles. The carbon dioxide ice particles themselves sublime without leaving residues. A sufficiently safe distance of cleaning personnel from the high-voltage carrying insulation component parts is ensured by the provision of an electrically insulating distance means (L, SFR) that is provided approximately in the form of a lance (L) or of a stream guided tube (SFR). A further increase in protection is offered by monitoring the quantity of moisture of compressed gas and/or ambient air, whereby the cleaning device is immediately shut off when predetermined limiting values are exceeded.

IPC 1-7

**B24C 1/00; B24C 5/02**

IPC 8 full level

**B24C 1/00** (2006.01); **B24C 5/02** (2006.01)

CPC (source: EP US)

**B24C 1/003** (2013.01 - EP US); **B24C 1/086** (2013.01 - EP US); **B24C 3/322** (2013.01 - EP US); **B24C 5/02** (2013.01 - EP US);  
**Y10T 137/0352** (2015.04 - EP US)

Cited by

CN107769051A; DE102010036295A1; US9255956B2; EP2612538B1

Designated contracting state (EPC)

AT BE CH CY DE DK ES FI FR GB GR IE IT LI LU MC NL PT SE TR

DOCDB simple family (publication)

**US 2003104764 A1 20030605; US 6863594 B2 20050308**; AT E246570 T1 20030815; DE 10112889 A1 20011018; DE 20104654 U1 20010913;  
DE 50100469 D1 20030911; EP 1263549 A1 20021211; EP 1263549 B1 20030806; ES 2204853 T3 20040501; WO 0168323 A1 20010920

DOCDB simple family (application)

**US 22161702 A 20020913**; AT 01923519 T 20010315; DE 0100994 W 20010315; DE 10112889 A 20010315; DE 20104654 U 20010315;  
DE 50100469 T 20010315; EP 01923519 A 20010315; ES 01923519 T 20010315